

AMENDMENTS TO THE CLAIMS

1. (Currently Amended) An organic electroluminescent device comprising:
 - a hole injection electrode;
 - a hole injection layer;
 - a light emitting layer; and
 - an electron injection electrode in this order, whereinsaid hole injection layer includes a first hole injection layer and a second hole injection layer,

said first hole injection layer having a property of absorbing ultraviolet light and including a ~~phthalocyanine-based compound copper phthalocyanine~~, said second hole injection layer including a ~~carbon-based halide formed by plasma chemical vapor deposition fluorocarbon~~.

2. (Original) The organic electroluminescent device according to Claim 1, wherein
said first hole injection layer absorbs not less than 10% of ultraviolet light having a wavelength shorter than 380 nm.

Claims 3-9 (Cancelled)

10. (Original) The organic electroluminescent device according to Claim 1, wherein
said first hole injection layer has a thickness not smaller than 5 nm.
11. (Original) The organic electroluminescent device according to Claim 1, wherein

said first hole injection layer has a thickness not larger than 15 nm.

12. (Original) The organic electroluminescent device according to Claim 1, wherein
said second hole injection layer has a thickness not smaller than 0.5 nm.

13. (Original) The organic electroluminescent device according to Claim 1, wherein
said second hole injection layer has a thickness not larger than 3 nm.

14. (Currently Amended) A method of manufacturing an organic electroluminescent device comprising the steps of:

forming a hole injection layer on a hole injection electrode; and

forming a light emitting layer and an electron injection electrode in this order above said hole injection layer, wherein

said step of forming said hole injection layer includes the steps of:

forming a first hole injection layer made of a phthalocyanine-based compound copper phthalocyanine, and having a property of absorbing ultraviolet light; and

forming a second hole injection layer made of a carbon-based-halide fluorocarbon on said first hole injection layer by plasma chemical vapor deposition.